Application No. 10/008,838

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#### Amendments to the Claims:

This listing of claims will replace all prior versions, and listings. of claims in the application:

Listing of Claims: 1-13. (CANCELLED)

- 14. (currently amended) A method of fabricating an acoustic resonator 1 2 comprising the steps of:
- 3 providing a substrate; and
- forming a membrane on said substrate such that at least a 4 5 portion of said membrane is suspended from contact with a substrate. 6 including:
- 7 forming an electrode-piezoelectric stack on said substrate such that a portion of said electrode-piezoelectric stack is suspended from 8 contact with said substrate by a cavity having a boundary defined by said 9 electrode-piezoelectric stack, said electrode-piezoelectric stack having a 10 negative temperature coefficient of frequency, and 11
- (a) forming an electrode-piezoelectric-stack having a 12 13 negative temperature coefficient of frequency, and
- (a) forming (b) forming a compensator layer, comprised of a ferromagnetic material, in direct contact with adjacent to said electrode-15 piezoelectric stack, including selecting a material for said compensator layer 16
- having a positive temperature coefficient of frequency. 17
- 15. (currently amended) The method of claim 14 wherein said step (a) 1
- stop (b) that includes selecting said material includes selecting a nickel-iron 2
- alloy.

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- 16. (currently amended) The method of claim 14 wherein said step (a) 1
- step (b) Includes depositing said material as approximately 35 percent nickel 2
- and approximately 65 percent iron.

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- 1 17. (currently amended) The method of claim 14 wherein said step (a)
- 2 step (b) includes selecting a layer thickness to substantially match a
- 3 magnitude of temperature-induced effects on resonance by operation of said
- 4 electrode-plezoelectric stack with a magnitude of temperature-induced effects
- 5 on said resonance as a consequence of said compensator layer.
- 1 18. (currently amended) The method of claim 14 wherein said step of
- 2 forming said compensator layer membrane further includes (b) forming
- 3 (c) forming a metallic flashing layer on a side of said compensator layer
- 4 opposite to said electrode-piezoelectric stack.
- 1 19. (currently amended) The method of claim 18 further comprising using
- 2 fabrication alignment techniques in said steps (a) and (b) steps (b) and (c) to
- 3 prevent spurious mode generation resulting from partial coverage of said
- 4 suspended membrane electrode-piezoelectric stack by said compensator
- 5 layer er-said flashing layer.

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